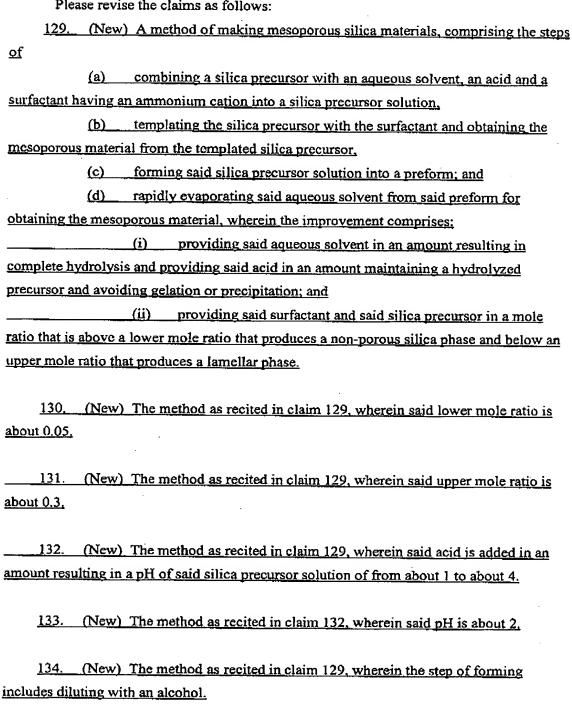
IN THE CLAIMS

Please revise the claims as follows:



135. (New) The method as recited in claim 134, wherein said alcohol is ethanol.

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136. (New) The method as recited in claim 129, wherein said aqueous solvent, said
acid, and said surfactant are premixed before combining with said silica precursor.
137. (New) The method as recited in claim 129, wherein said mesoporous material
are in a geometric form selected from the group consisting of fiber, powder, and film.
138. (New) The method as recited in claim 129, wherein said forming is spin-
casting.
139. (New) The method as recited in claim 129, wherein said forming is spraying.
140 07) 77 11 11 11 11 11 11 11 11 11
140. (New) The method as recited in claim 129, further comprising adding a pre-
polymer or a polymer to said silica precursor solution making a pituitous mixture.
141. (New) The method as recited in claim 129, wherein said forming is drawing.
142. (New) The method as recited in claim 129, wherein said forming is
squeegeeing.
143. (New) The method as recited in claim 129, further comprising the step of
adding a metal compound to the silica precursor solution.
144 (Nove) The mothed as a size of the 142 of the size
144. (New) The method as recited in claim 143, wherein said metal compound is
selected from the group consisting of metal halide, metal nitrate, and combinations thereof.
145. (New) The method as recited in claim 144, wherein said metal halide is a
metal chloride.
146. (New) The method as recited in claim 144, wherein said metal is selected from
the group of aluminum, iron and combinations thereof.

147. alkoxide sili	(New) The method as recaptor or a tetrachlo		rein said silica precursor is an
148. amount is ch	(New) The method as recarred by a ratio of sa		rein said aqueous solvent said silica precursor of about 7.
149.	(New) The method as rec	•	
	(New) The method as rec		er comprising adding a
151. 1,3,5-trimeth		cited in claim 150, wher	ein said swelling agent is
	(New) The method as recommesoporous material.	ited in claim 129, furth	er comprising the step of
		precursor with an aque	film, comprising the steps of ous solvent, an acid and a
	(b) templating the siliconaterial from the template	ca precursor with the su	rfactant and obtaining the
obtaining the	(d) rapidly evaporating mesoporous material, who	g said aqueous solvent i	from said preform for comprises;
and providing	(ii) providing s said acid in an amount m	aid aqueous solvent in a	a superstoichiometric amount
ratio that is al	(iii) providing s	at produces a non-porou	silica precursor in a mole us silica phase and below and
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(iv) said forming includes diluting with an alcohol.
154. (New) The method as recited in claim 153, further comprising adding a pre- polymer or a polymer to said silica precursor solution making a pituitous mixture.
155. (New) The method as recited in claim 153, wherein said rapidly evaporating is by spin-casting.
156. (New) A method of making a mesoporous film on a substrate, the method comprising the steps of:
(a) combining a silica precursor with an aqueous solvent, an acid catalyst and an ammonium cationic surfactant into a precursor solution;
(b) dispensing said precursor solution onto the substrate; (c) forming a film by evaporation of the solvent in less than 5 minutes; and (d) heating the film on the substrate to a temperature sufficient to
decompose the surfactant, thereby producing a mesoporous film on the substrate. 157. (New) The method of claim 156 wherein the precursor solution is a silica
precursor solution and wherein the surfactant and the silica precursor solution are in a mole
ratio that is above a lower mole ratio that produces a non-mesoporous silica phase and
below an upper mole ratio that produces a lamellar phase.
158. (New) The process of claim 156, wherein the film exhibits an index of refraction between 1.16 and that of silica.
159. (New) A process to form mesostructured films, comprising:
(a) preparing a precursor sol containing a soluble source of silica, an
aqueous solvent, an ammonium cationic surfactant and an acid catalyst; and
(b) depositing the precursor sol on a substrate wherein evaporation of
solvent and water in less than 5 minutes causes the formation of said mesostructured films
on the substrate surface.

160. (New) The process of claim 159 wherein the aqueous solvent and the cataly
are provided in amounts that maintain a hydrolyzed precursor sol while avoiding gelation
precipitation.
161. (New) The process of claim 159 wherein the soluble source of silica is a sili
precursor alkoxide or tetrachlorosilane and wherein the surfactant and the soluble source of
silica are in a mole ratio that is above a lower mole ratio that produces a non-porous silica
phase and below an upper mole ratio that produces a lamellar phase.
162. (New) The process of claim 159, wherein the ammonium cationic surfactant
further includes alkyl triethylammonium chloride or bromide surfactants with different
chain lengths.
163. (New) The process of claim 159, further comprising the step of calcining sai
film at 450°C.
164. (New) The process of claim 159, wherein the precursor sol is deposited on a
substrate by spin coating.
165. (New) The process of claim 159, wherein said soluble source of silica is an
165. (New) The process of claim 159, wherein said soluble source of silica is an alkoxide silica precursor or tetrachlorosilane.
and street precursor of tetracinorostratie.
166. (New) The process of claim 159, wherein the films exhibit an index of
refraction between 1.16 and that of silica.
167. (New) A process to form a mesoporous structure, comprising:
(a) preparing a precursor sol containing a soluble source of silica, an
alcohol and water solvent, an ammonium cationic surfactant, and an acid catalyst, wherein
said solvent is provided in an amount resulting in complete hydrolysis and said acid catalys
is in an amount to maintain a hydrolyzed precursor and to avoid gelation or precipitation in
said precursor sol;
(b) forming the precursor sol into a preform;

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mesostructured material; and (d) calcining the mesostructured material to form a mesoporous structure. 168. (New) The process of claim 167, wherein said precursor sol contains alcohol which is a hyproduct of hydrolysis, and said mesoporous structure is a film. 169. (New) The process of claim 167, wherein said preform is a droplet, said alcohol is a hyproduct of hydrolysis, and said sol is spray dried to form a powder. 170. (New) The process of claim 167, wherein said drying is preformed in less than 5 minutes. 171. (New) The process of claim 167, wherein said precursor sol contains dilutant alcohol, and wherein the mesoporous structure is a film. 172. (New) The process of claim 167, wherein the mesoporous structure is a film and wherein the film exhibits an index of refraction of between 1.16 and that of silica. 173. (New) The process of claim 167, wherein the said precursor sol contains alcohol which is a hyproduct of hydrolysis, and wherein said mesostructure is a film. 174. (New) The process of claim 173, wherein the film exhibits an index of refraction of between 1.16 and that of silica. 175. (New) The process of claim 167, wherein said precursor sol is spray dried. 176. (New) The process of claim 167, wherein said evaporating is performed in less than 5 minutes. 177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.		(c) evaporating said solvent from the preform at a rate that forms a
168. (New) The process of claim 167, wherein said precursor sol contains alcohol which is a byproduct of hydrolysis, and said mesoporous structure is a film. 169. (New) The process of claim 167, wherein said preform is a droplet, said alcohol is a byproduct of hydrolysis, and said sol is spray dried to form a powder. 170. (New) The process of claim 167, wherein said drying is preformed in less than 5 minutes. 171. (New) The process of claim 167, wherein said precursor sol contains dilutant alcohol, and wherein the mesoporous structure is a film. 172. (New) The process of claim 167, wherein the mesoporous structure is a film and wherein the film exhibits an index of refraction of between 1.16 and that of silica. 173. (New) The process of claim 167, wherein the said precursor sol contains alcohol which is a byproduct of hydrolysis, and wherein said mesostructure is a film. 174. (New) The process of claim 173, wherein the film exhibits an index of refraction of between 1.16 and that of silica. 175. (New) The process of claim 167, wherein said precursor sol is spray dried. 176. (New) The process of claim 167, wherein said evaporating is performed in less than 5 minutes. 177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.	mesostructur	ed material; and
which is a byproduct of hydrolysis, and said mesoporous structure is a film. 169. (New) The process of claim 167, wherein said preform is a droplet, said alcohol is a byproduct of hydrolysis, and said sol is spray dried to form a powder. 170. (New) The process of claim 167, wherein said drying is preformed in less than 5 minutes. 171. (New) The process of claim 167, wherein said precursor sol contains dilutant alcohol, and wherein the mesoporous structure is a film. 172. (New) The process of claim 167, wherein the mesoporous structure is a film and wherein the film exhibits an index of refraction of between 1.16 and that of silica. 173. (New) The process of claim 167, wherein the said precursor sol contains alcohol which is a hyproduct of hydrolysis, and wherein said mesostructure is a film. 174. (New) The process of claim 167, wherein the film exhibits an index of refraction of between 1.16 and that of silica. 175. (New) The process of claim 167, wherein said preform is a droplet, wherein said alcohol is a byproduct of hydrolysis, and wherein said precursor sol is spray dried. 176. (New) The process of claim 167, wherein said evaporating is performed in less than 5 minutes. 177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.		(d) calcining the mesostructured material to form a mesoporous structure.
which is a byproduct of hydrolysis, and said mesoporous structure is a film. 169. (New) The process of claim 167, wherein said preform is a droplet, said alcohol is a byproduct of hydrolysis, and said sol is spray dried to form a powder. 170. (New) The process of claim 167, wherein said drying is preformed in less than 5 minutes. 171. (New) The process of claim 167, wherein said precursor sol contains dilutant alcohol, and wherein the mesoporous structure is a film. 172. (New) The process of claim 167, wherein the mesoporous structure is a film and wherein the film exhibits an index of refraction of between 1.16 and that of silica. 173. (New) The process of claim 167, wherein the said precursor sol contains alcohol which is a hyproduct of hydrolysis, and wherein said mesostructure is a film. 174. (New) The process of claim 167, wherein the film exhibits an index of refraction of between 1.16 and that of silica. 175. (New) The process of claim 167, wherein said preform is a droplet, wherein said alcohol is a byproduct of hydrolysis, and wherein said precursor sol is spray dried. 176. (New) The process of claim 167, wherein said evaporating is performed in less than 5 minutes. 177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.		
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174. (New) The process of claim 173, wherein the film exhibits an index of refraction of between 1.16 and that of silica. 175. (New) The process of claim 167, wherein said preform is a droplet, wherein said alcohol is a byproduct of hydrolysis, and wherein said precursor sol is spray dried. 176. (New) The process of claim 167, wherein said evaporating is performed in less than 5 minutes. 177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.		
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175. (New) The process of claim 167, wherein said preform is a droplet, wherein said alcohol is a byproduct of hydrolysis, and wherein said precursor sol is spray dried. 176. (New) The process of claim 167, wherein said evaporating is performed in less than 5 minutes. 177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.	174	(Nov.) The process of alaim 172 mhanning to 51 and 174
175. (New) The process of claim 167, wherein said preform is a droplet, wherein said alcohol is a byproduct of hydrolysis, and wherein said precursor sol is spray dried. 176. (New) The process of claim 167, wherein said evaporating is performed in less than 5 minutes. 177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.		·
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said alcohol is a byproduct of hydrolysis, and wherein said precursor sol is spray dried. 176. (New) The process of claim 167, wherein said evaporating is performed in less than 5 minutes. 177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.	1 7 5	(New) The process of claim 167 wherein said preform is a deaplot wherein
176. (New) The process of claim 167, wherein said evaporating is performed in less than 5 minutes. 177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.		
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177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.	176.	(New) The process of claim 167, wherein said evaporating is performed in
177. (New) The process of claim 167, wherein said soluble source of silica includes a silica alkoxide precursor or tetrachlorosilane.		
includes a silica alkoxide precursor or tetrachlorosilane.		
includes a silica alkoxide precursor or tetrachlorosilane.	177.	(New). The process of claim 167, wherein said soluble source of silica
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(a) preparing a precursor sol containing a soluble source of silica, an alcohol and water solvent, an ammonium cationic surfactant, and an acid catalyst, wherein
alcohol and water solvent, an ammonium cationic surfactant, and an acid catalyst, wherein
said solvent is provided in an amount resulting in complete hydrolysis and said acid is in
amount to maintain a hydrolyzed precursor and to avoid gelation or precipitation in said
precursor sol;
(b) forming the precursor sol into a preform;
(c) evaporating said solvent from the preform at a rate that forms a
mesostructured material, wherein said mesostructured material contains surfactant; and
(d) calcining the mesostructured material to form a mesoporous structure.
179. (New) A process to form a mesostructure, comprising:
(a) preparing a precursor sol containing a soluble source of silica, water
and alcohol solvent, an ammonium cationic surfactant and an acid catalyst; and
(b) evaporating said solvent in less than 5 minutes to cause the formation of
a mesostructure, wherein said mesostructure contains surfactant.
180. (New) The process of claim 179, wherein the mesostructure is a film, and
wherein the film exhibits an index of refraction of between 1.16 and that of silica.
181. (New) A process to form a mesostructure, comprising:
(a) preparing a precursor sol containing a soluble source of silica, a water
and alcohol solvent, an ammonium cationic surfactant and an acid catalyst, and
(b) evaporating said solvent in less than 5 minutes to cause the formation of
a mesostructure.
182. (New) The process of claim 181, wherein said solvent is evaporated in less
than 1 minute,
183. (New) The process of claim 181, wherein said solvent is evaporated in less
than 10 seconds.

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184. (New) The process of claim 183, wherein the mesostructure is a film, and wherein the film exhibits an index of refraction of between 1.16 and that of silica.	
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185. (New) The process of claim 181, wherein the said precursor sol contains	
both dilutant alcohol and alcohol which is a byproduct of hydrolysis, and wherein said	
mesostructure is a film.	
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186. (New) The process of claim 181, wherein said preform is a droplet, said	
alcohol is a byproduct of hydrolysis, and said sol is spray dried.	
187. (New) The process of claim 181, wherein the ammonium cationic surfactant	
further includes alkyl triethylammonium chloride or bromide surfactants with different	
chain lengths.	
188. (New) A calcined mesoporous silica film on a substrate formed by a process	
comprising:	
dispensing an acid catalyst- and silica precursor- and aqueous solvent- and	
surfactant-containing solution on the substrate:	
forming a film on the substrate by rapid evaporation of the solution on the substrate;	
heating the film on the substrate for a time and to a temperature sufficient	
substantially to remove any residual solvent; and	
calcining the film at a temperature at or above 350°C.	
189. (New) A calcined mesoporous silica film on a substrate formed by a process	/
comprising:	
dispensing a catalyst- and silica precursor- and solvent- and surfactant-containing	
solution on the substrate;	
forming a film on the substrate by rapid evaporation of the solution on the substrate;	
and	/
heating the film on the substrate for a time and to a temperature sufficient	
substantially to remove any residual solvent; and	
calcining the film at a temperature at or above 350°C.	
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